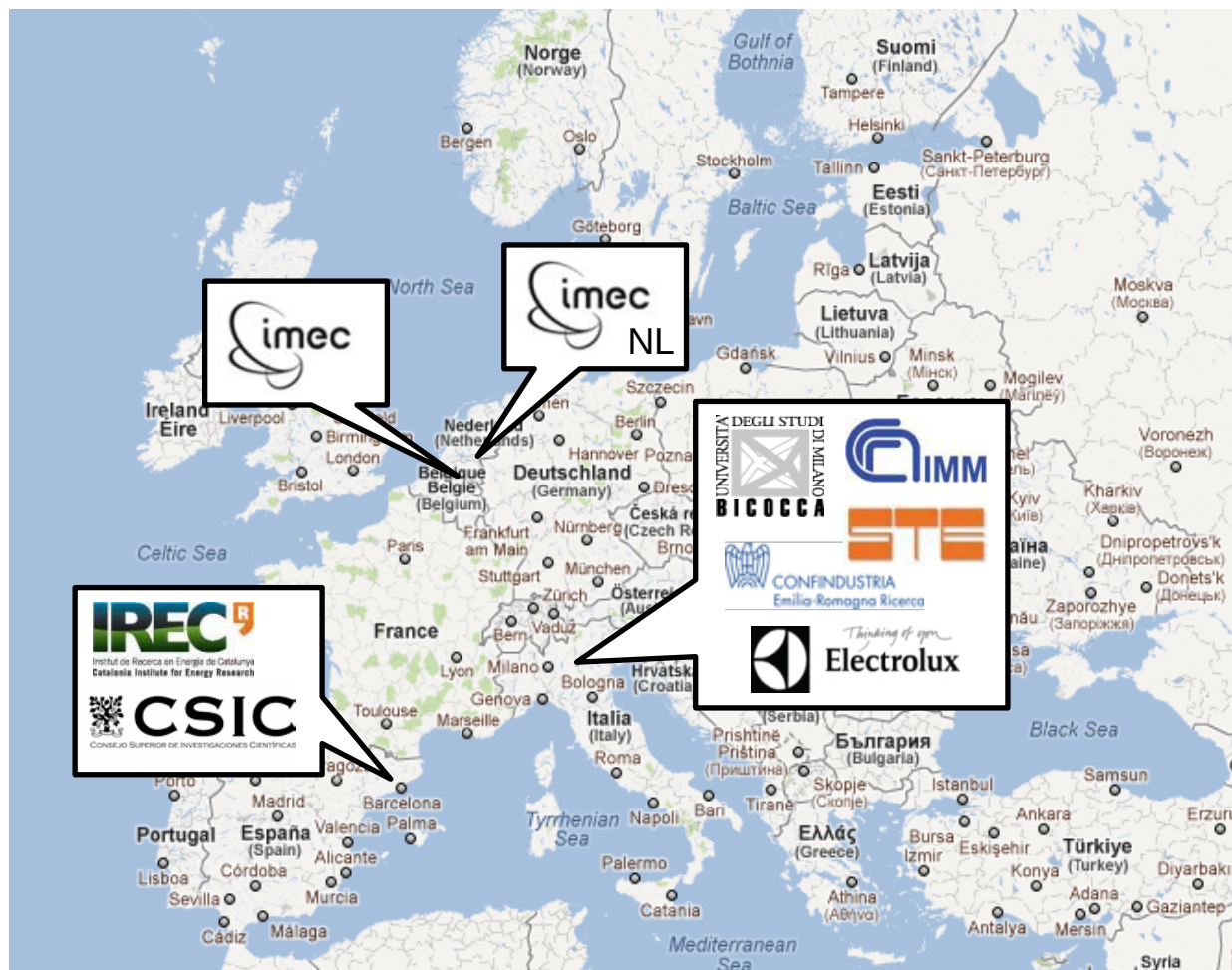


Silicon micro-nanotechnologies and compatible materials for the energy autonomy of small devices



L. Fonseca
IMB-CNM (CSIC)

sinergy-project.eu



9 partners
(ES, IT, BE, NL)

Coordinator:
CSIC
(IMB-CNM)

- Title:** Silicon Friendly Materials and Device solutions for Microenergy Applications
- Acronym:** **SiNERGY**
- Call/topic:** NMP.2013.2.2 -4 Materials solutions for durable energy harvesters
- Duration:** 36 months
- Funding:** 3,794,913.00 € (4.824.460.00 €)
- Partners:** 9 (4 countries) - **coordinated by** Luis Fonseca (CSIC)

Goal: Silicon materials and Silicon technologies & architectures for long term autonomy microenergy solutions

Focus: (1) Technology development at device level (2) Systems integration feasibility

Devices: (1) Harvesters based on thermoelectrics (2) Harvesters based on mechanical vibrations (3) thin film / 3D batteries

Silicon
(compatible)

energy

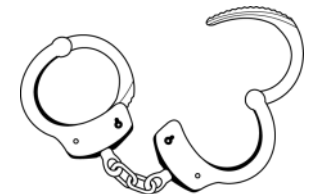
technology

small

devices



In the wide open skies of material research.. Why to restrict to the silicon family?



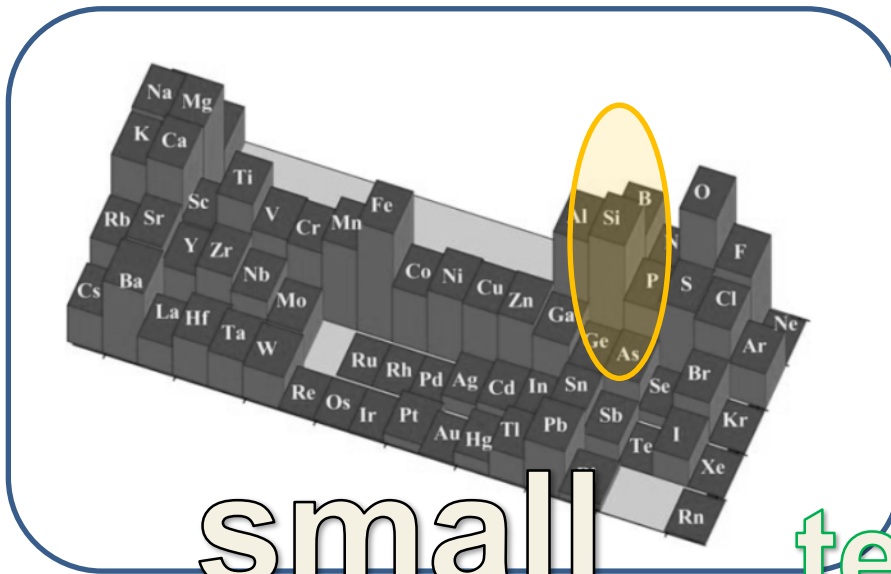
Chains do not only restrain...



Drag & haul

Engrain & move

Enabling aspects of Silicon materials and architectures:



- Abundant material
- Mature fabrication technology
- Cost effectiveness and economy of scale
- Miniaturized systems and dense architectures

small technology
devices

... Silicon friendly?

- Silicon and close Silicon relatives thin film subtractive and top-down standard technologies
 - Materials/processes compatible with the Si devices or the Si fab infrastructure:
 - Post-processing
 - Processing temperature
 - Wafer level
 - Include bottom-up
- Silicon
(compatible)
technology

Why microenergy solutions:

Small Power for the next Big Thing

IoT

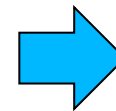


IMEZ TORRE/CHN

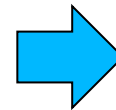


T SENSORS SUMMIT FOR TRILLION SENSOR ROADMAP

devices



Functional autonomy

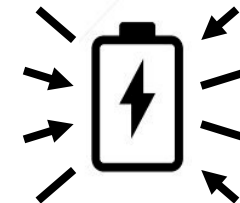


Energy autonomy



grid

off-grid



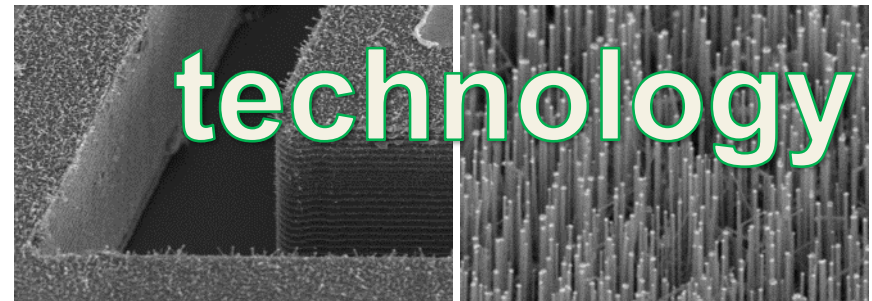
Energy harvesting



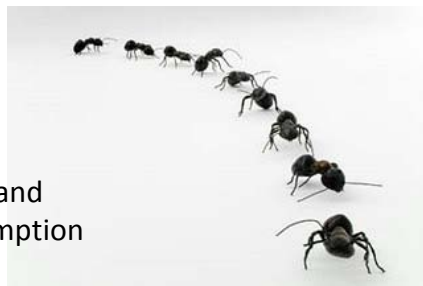
Get the energy, or replenish the battery, from the environment

If many (sensors), better...

- Small
- but internally 'dense'



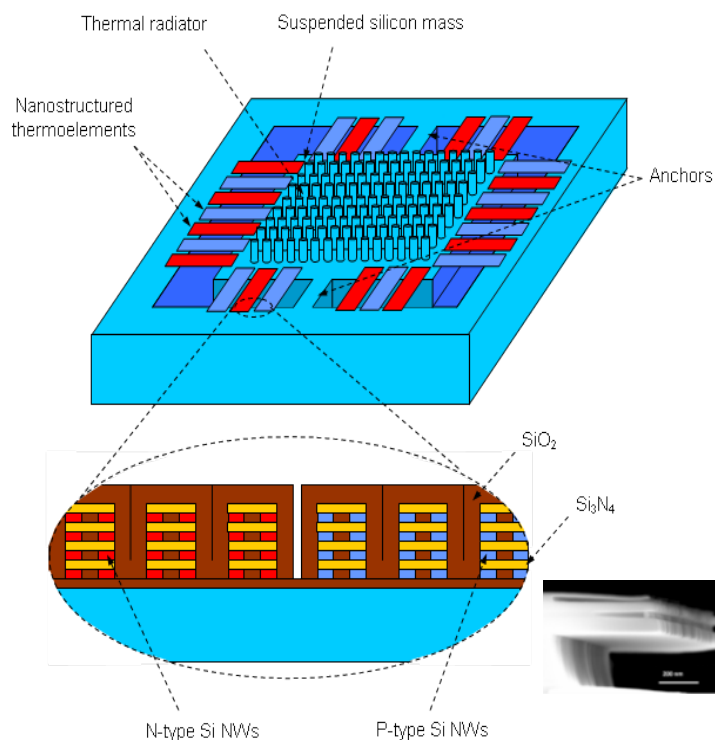
Less material and
energy consumption



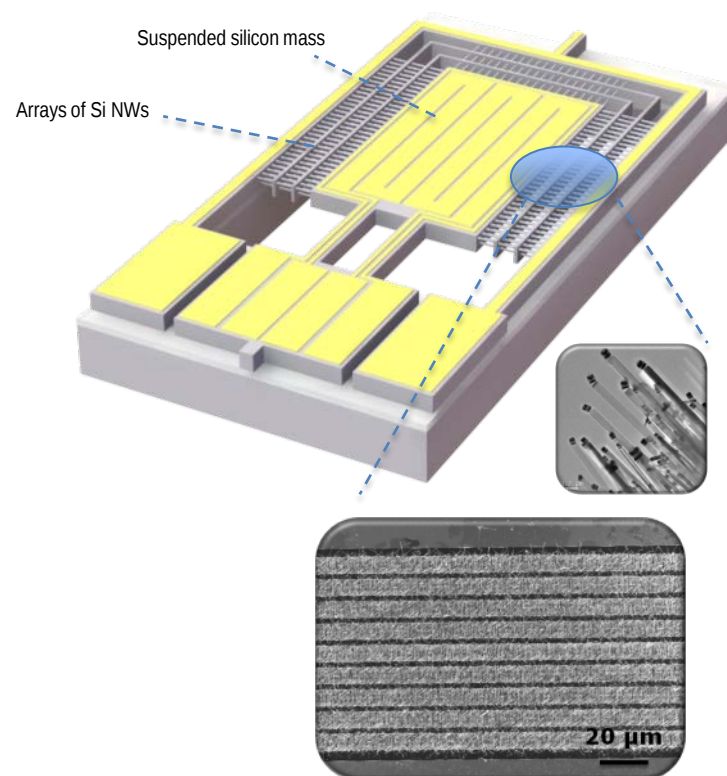
small

- Micromachining: free surfaces & volumes (coupling with the environment)
- 3D architectures (where to integrate nanomaterials)
- high aspect ratios / high density features

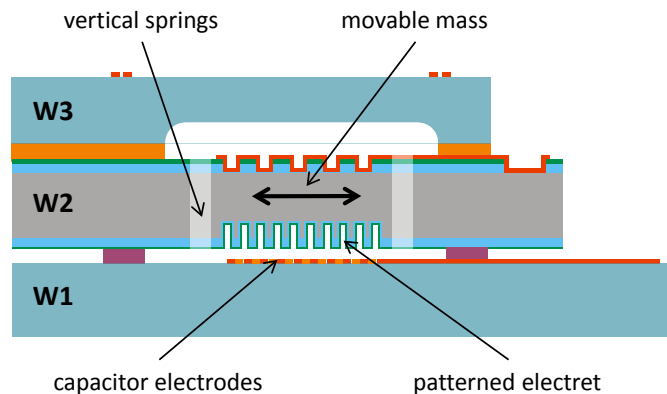
- 3D microstructures
+ top-down Si NWs



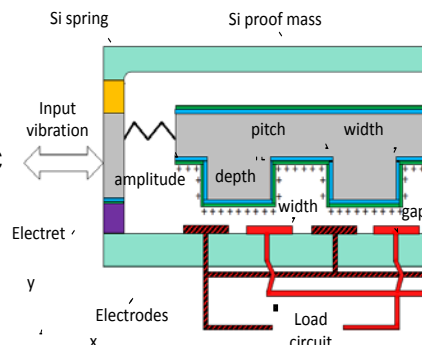
- 3D microstructures
+ bottom-up Si NWs



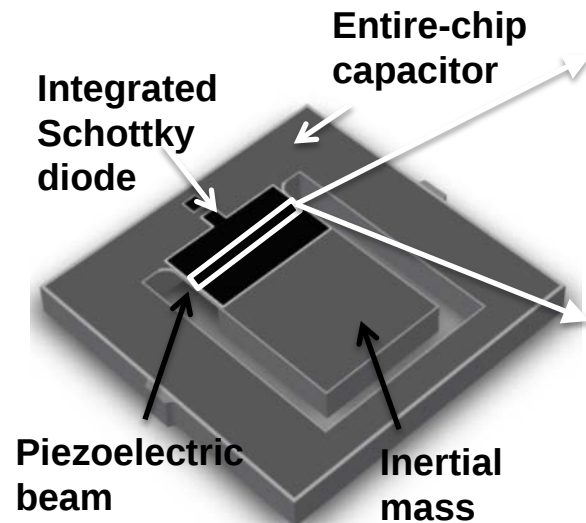
- 3D microstructures
+ thin films



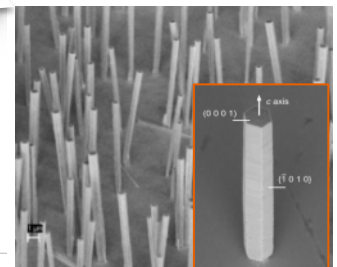
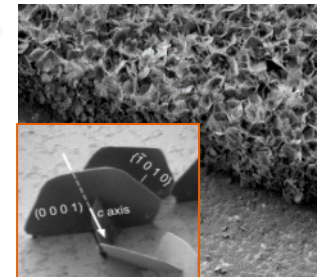
Electrostatic action



- 3D microstructures
+ bottom-up ZnO nanoX



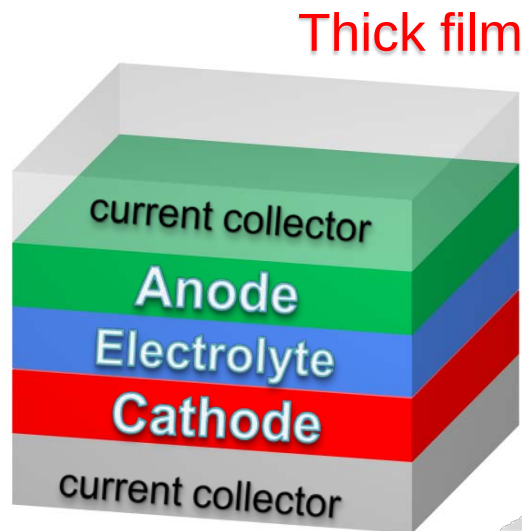
nanosheets



nanowires

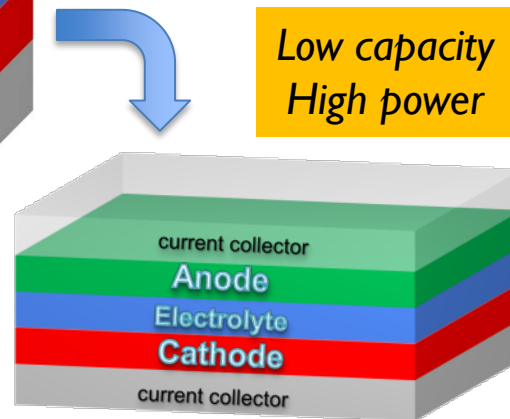
- Materials for Si compatible batteries

- 3D microstructures



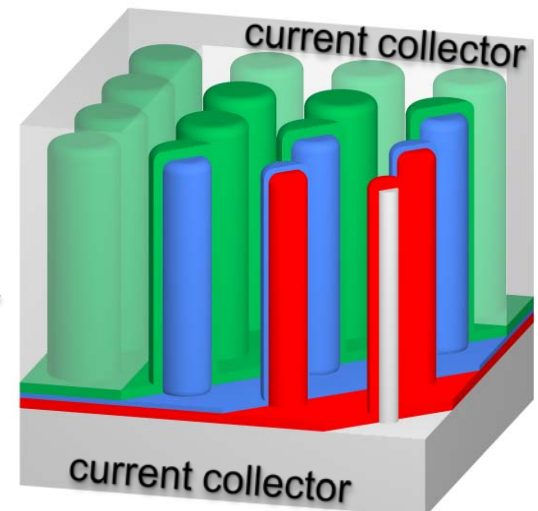
*High capacity
Low power*

Thin film

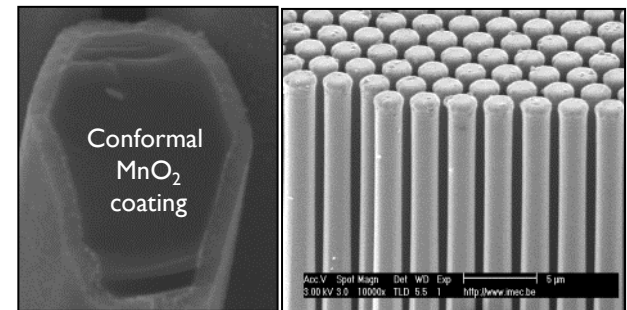


*Low capacity
High power*

3D

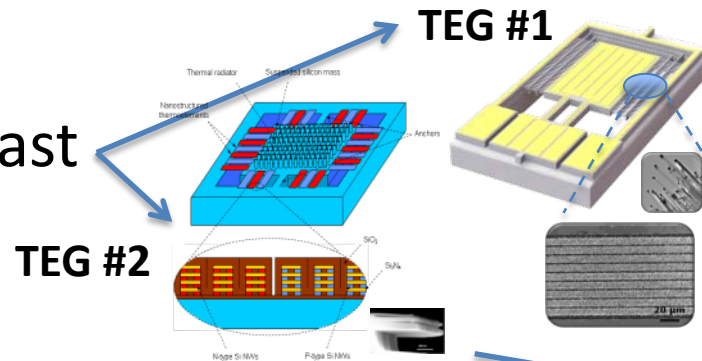


High capacity & power



3D microstructures + materials

➤ Thermal contrast

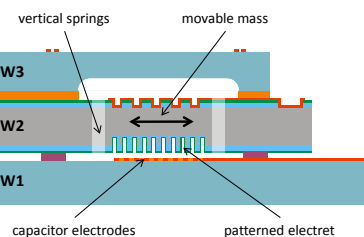
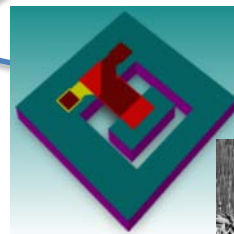


➤ Nanomaterials:

**post-growth*
• *Bottom-up*

➤ Moving masses

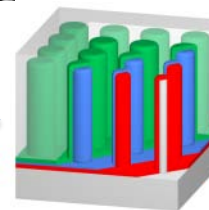
piezoelectric



electrostatic

• *Top-down*

➤ high aspect ratio support



Solid state battery

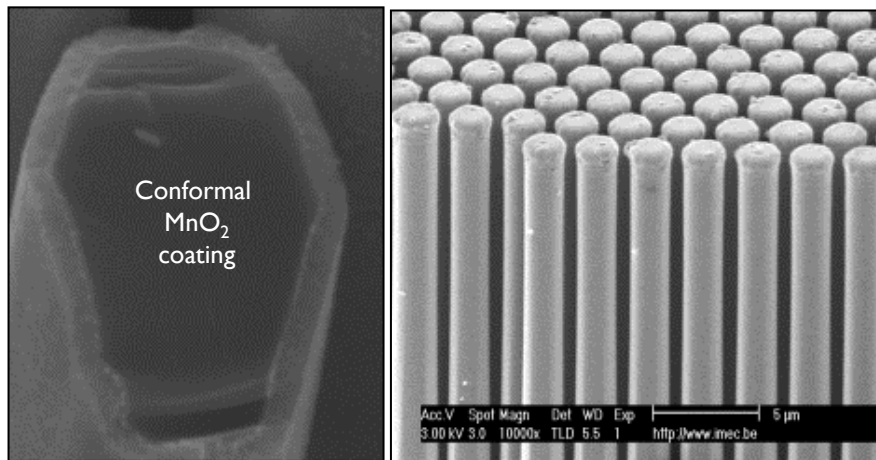
➤ Thin film materials

**post-lithiation*

Solid State microbatteries

Post-lithiation

- Li is instrumental in batteries electrodes and electrolytes
- Li is not a Silicon compatible material



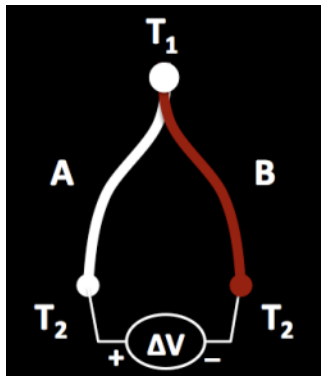
- Li-free conformal deposition (e.g. MnO_2 , TiO_2) by ALD or ECD
- Lithiation (into LTO or LMO) by a solid state reaction as a post-process

Thermal Energy Harvesting

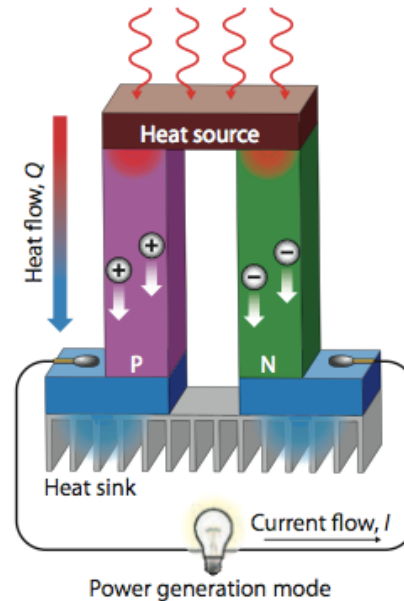
Integration of SiNWs

Thermal energy harvesting: heat into electricity

$$V = (S_A - S_B) \cdot \Delta T$$

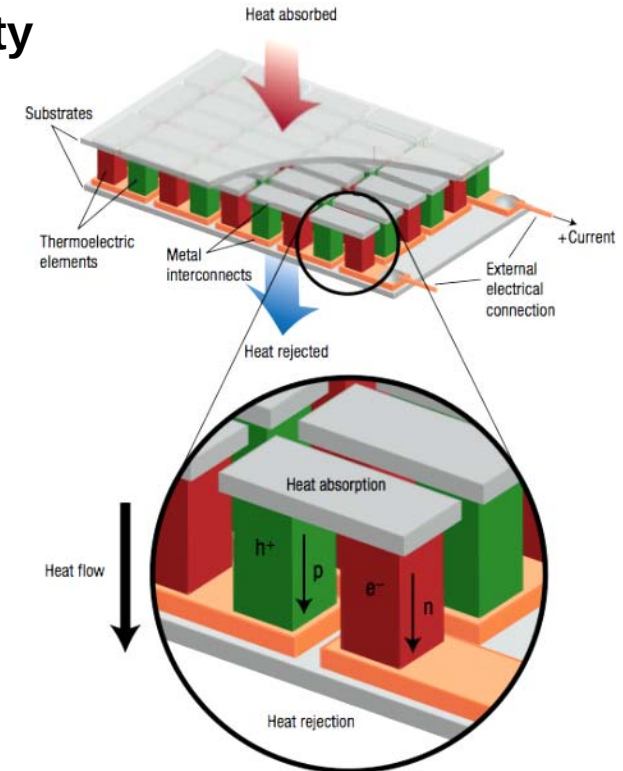


Thermoelectric generation (TEG)



Schematic illustrations of a thermoelectric element for power generation (Seebeck effect).

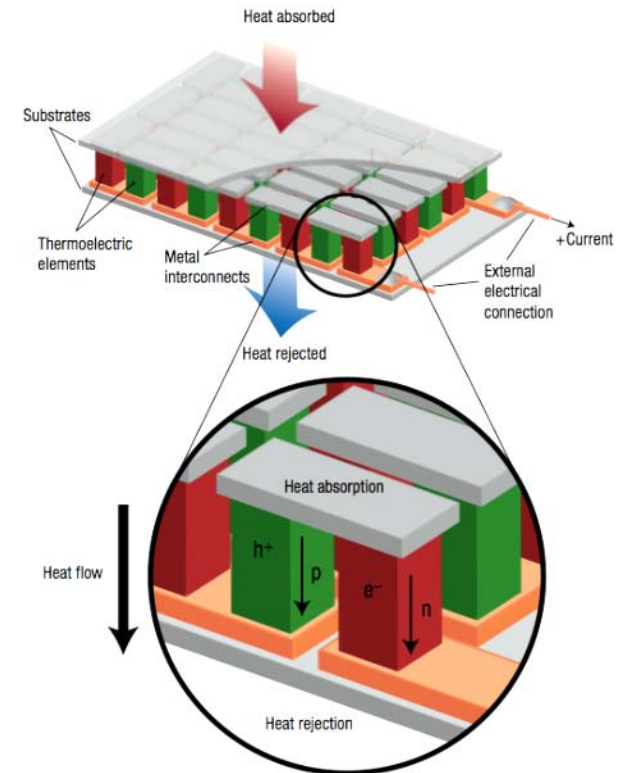
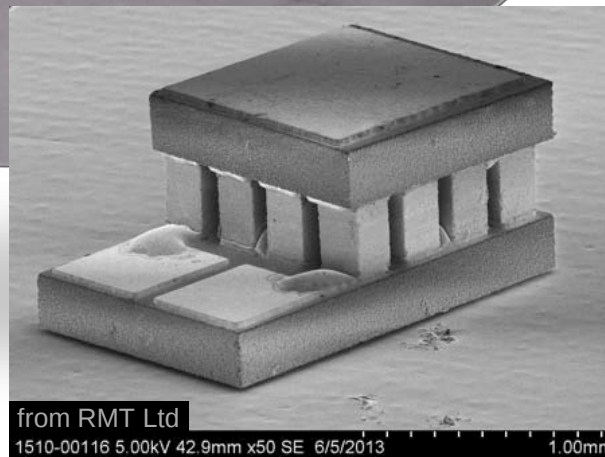
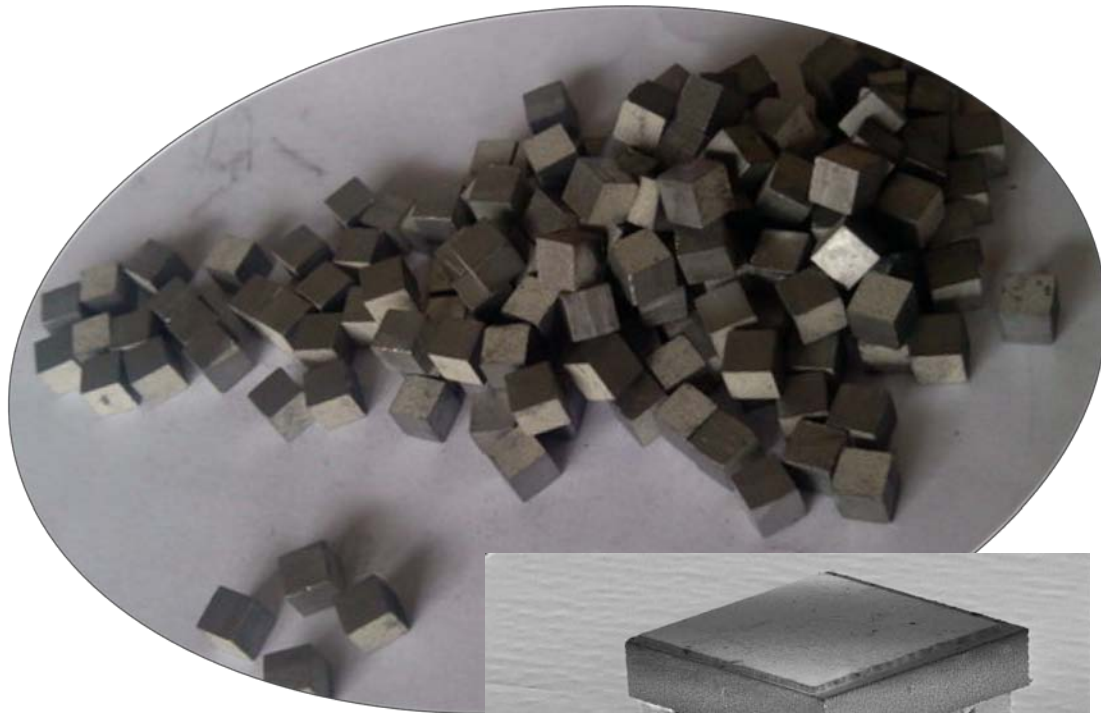
Li et al. NPG Asia Mater. 2, 152 (2010)



Snyder and Toberer Nature Mater. 7, 105 (2008)

- Efficiency of a thermoelectric material $\rightarrow ZT$
- Good thermoelectric materials $\rightarrow ZT > 1$

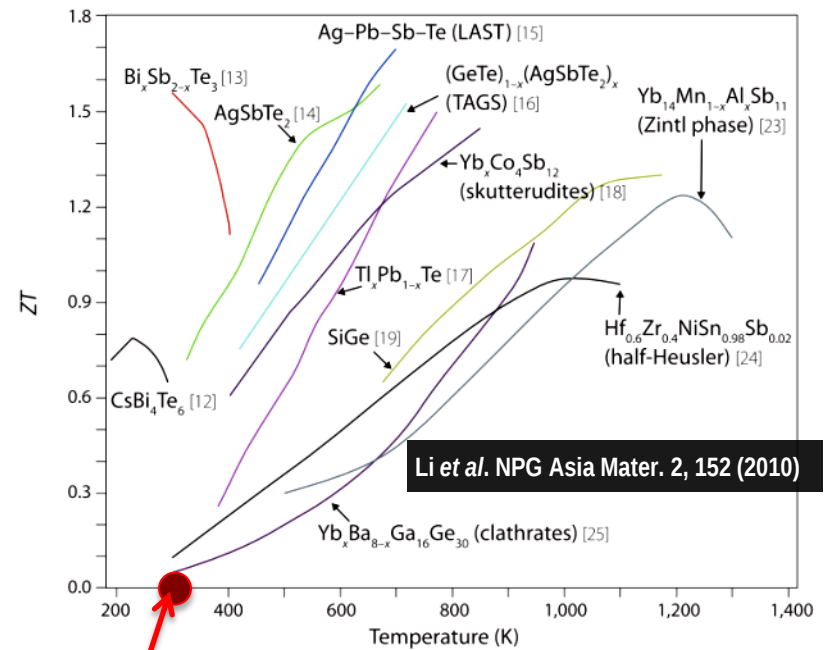
$$ZT = (S^2 \sigma / \kappa) T$$



Snyder and Toberer Nature Mater. 7, 105 (2008)

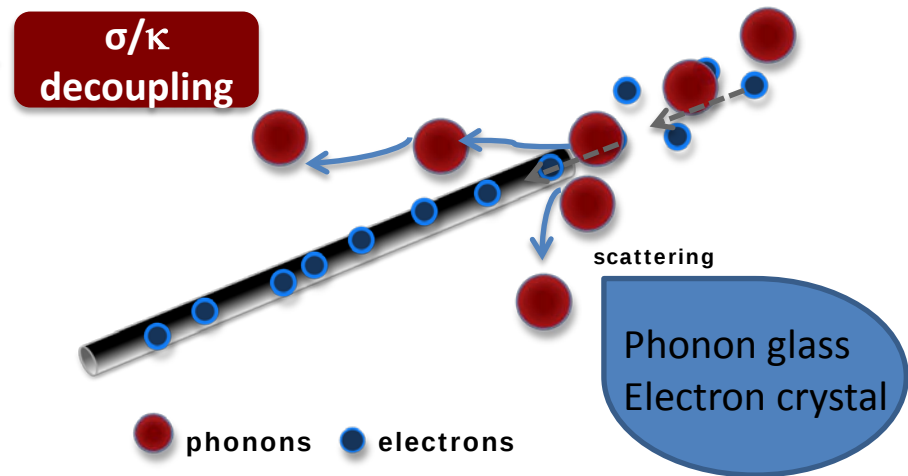
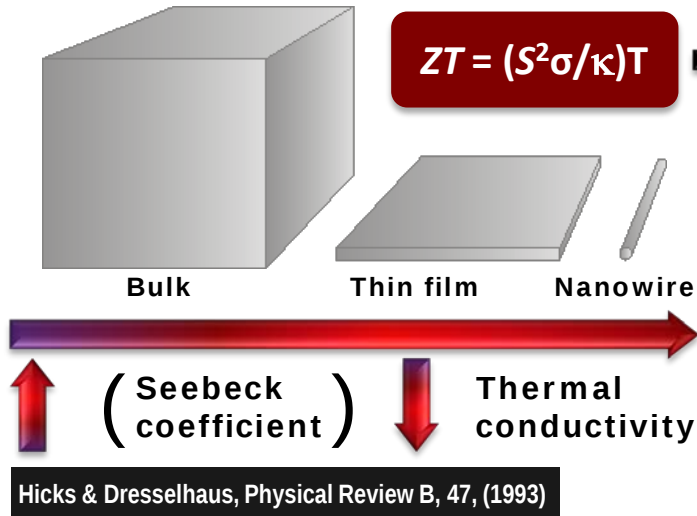
$$ZT = (S^2\sigma/\kappa)T$$

- Silicon: technology giant - thermoelectric dwarf



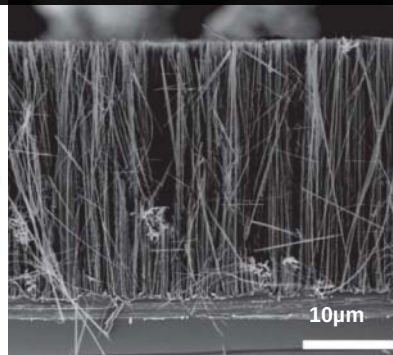
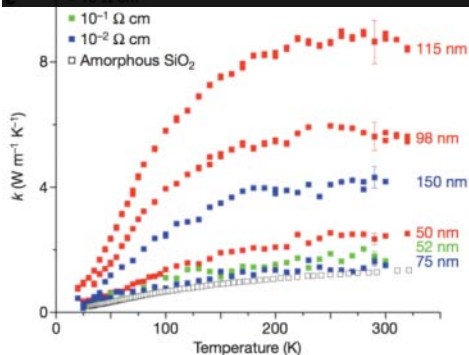
**Bulk silicon
($ZT \approx 0.01$)**



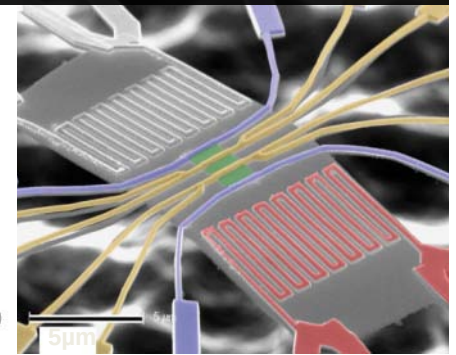
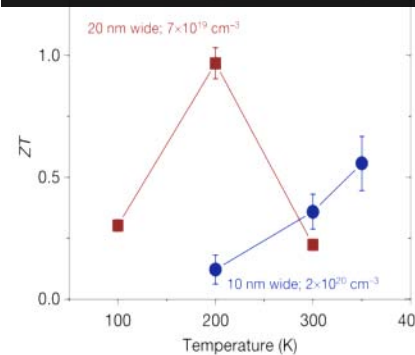


SINGLE SILICON NANOWIRES with $ZT \approx 1 \rightarrow$ (2008)

Hochbaum et al. Nature 451, 163 (2008) / 100-fold reduction of κ / $ZT=0.6$ at RT



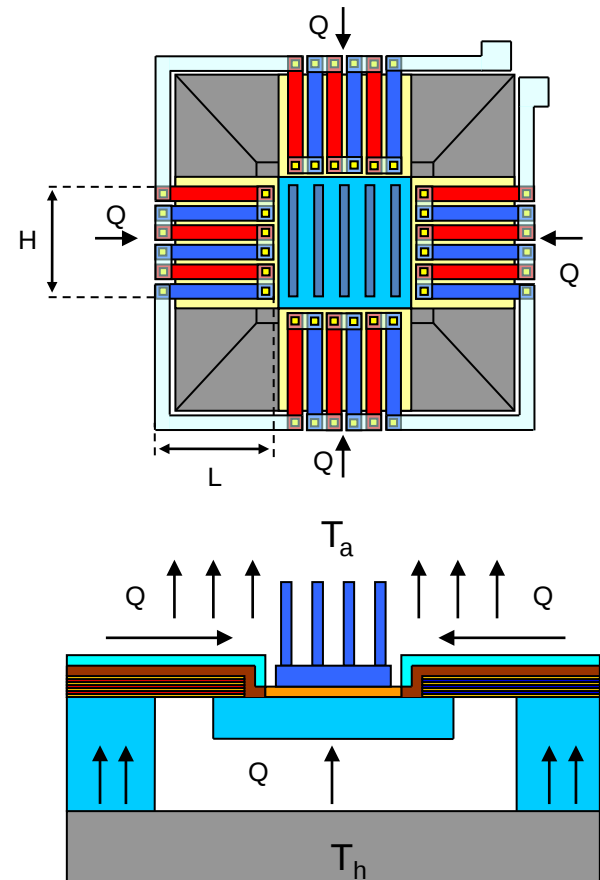
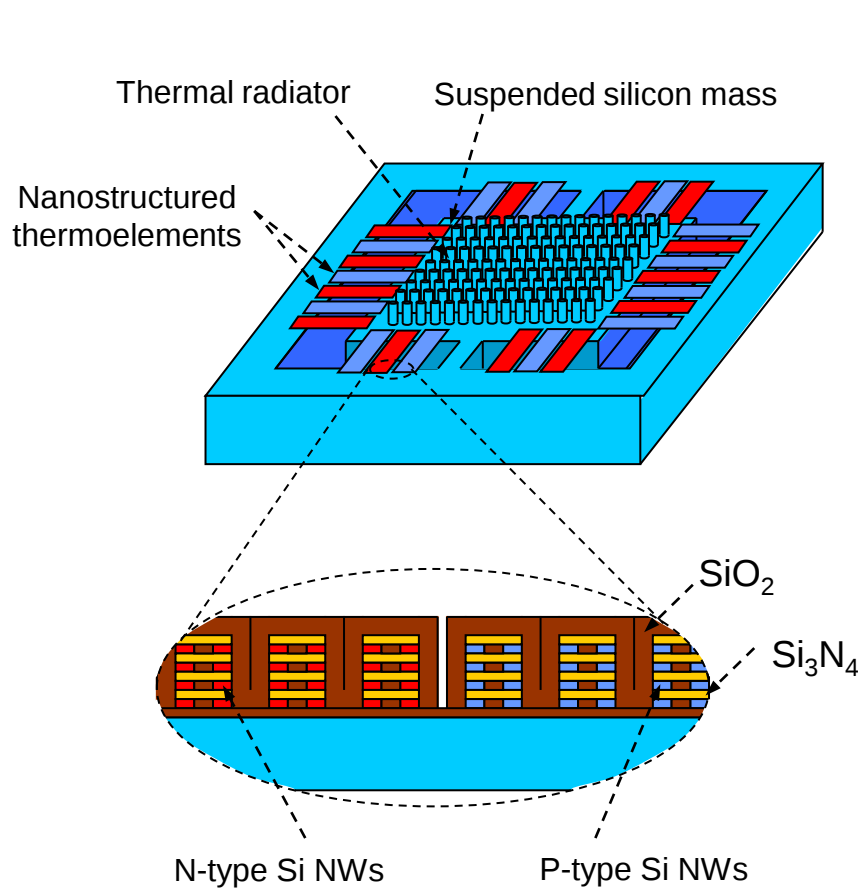
Boukai et al. Nature 451, 168 (2008) / $ZT \rightarrow$ 100-fold improv. bulk Si / $ZT \approx 1$ at 200 K



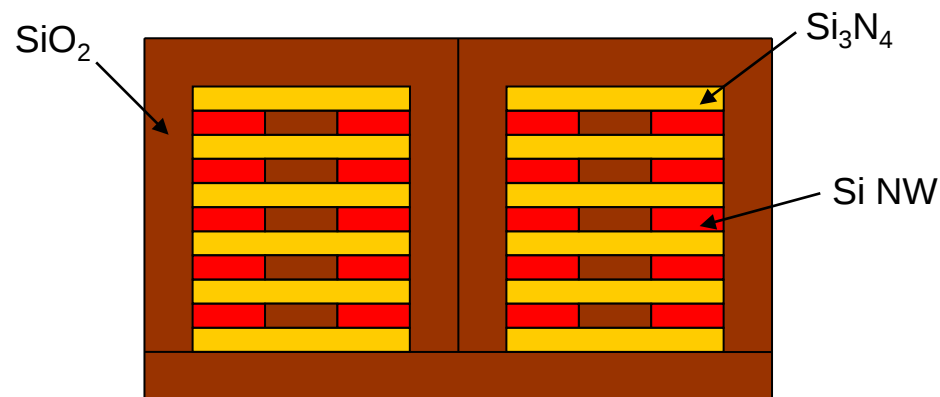
Thermal Energy Harvesting

**Silicon compatible
TOP-DOWN nanomaterial
(Si NWs)**

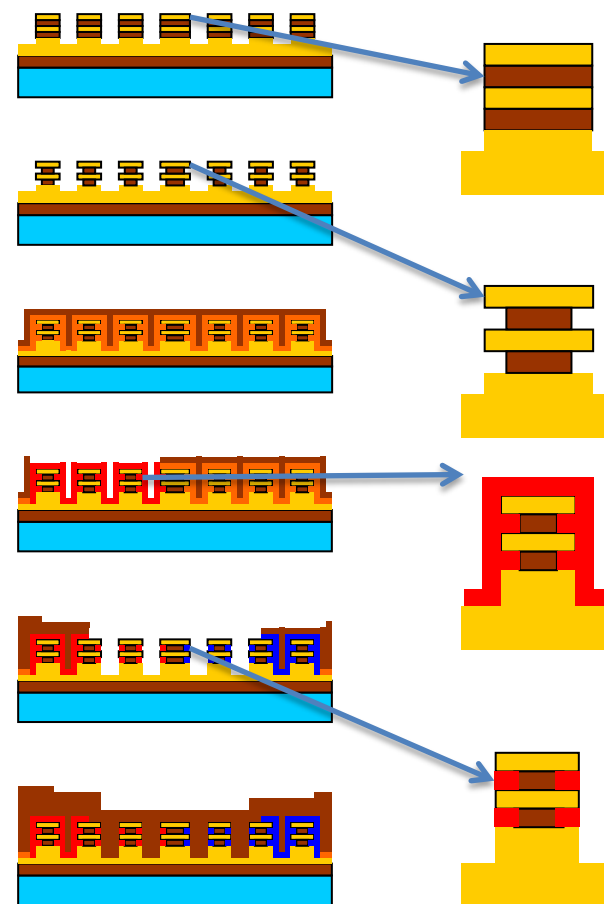
Planar architecture (suspended platform to force a lateral gradient)

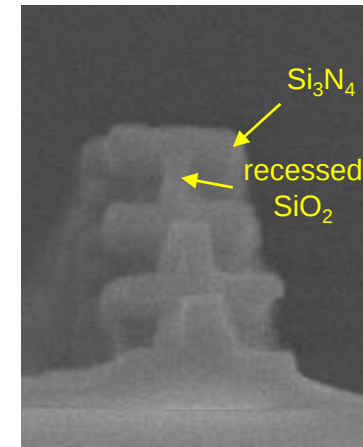
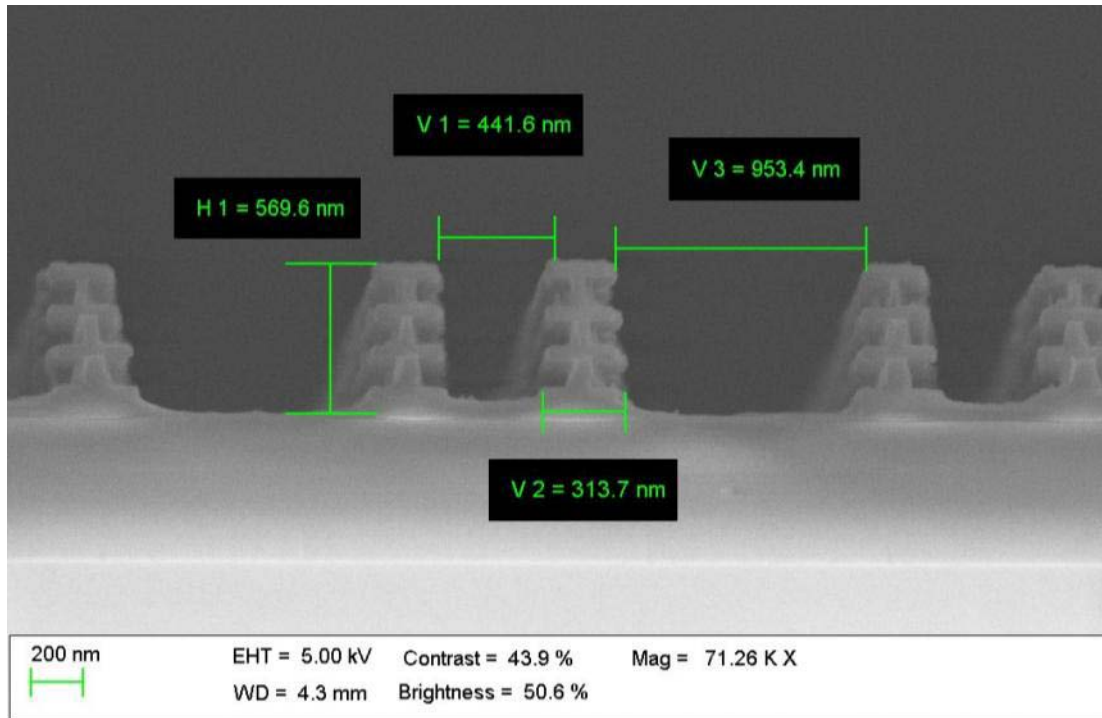


Cross-section of nanostructured thermoelement



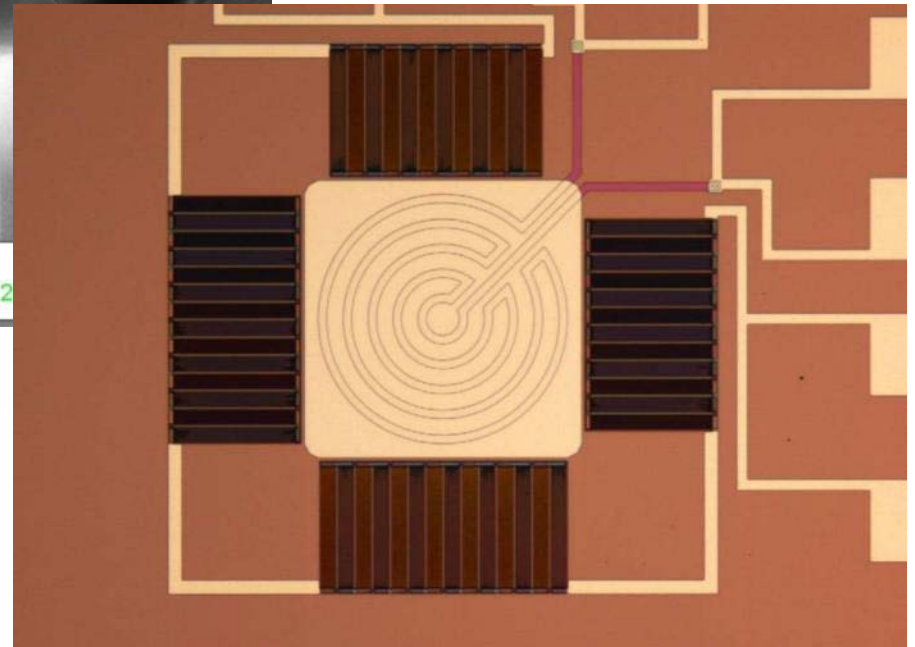
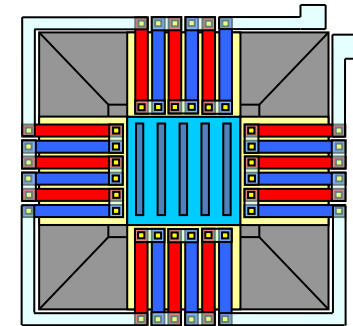
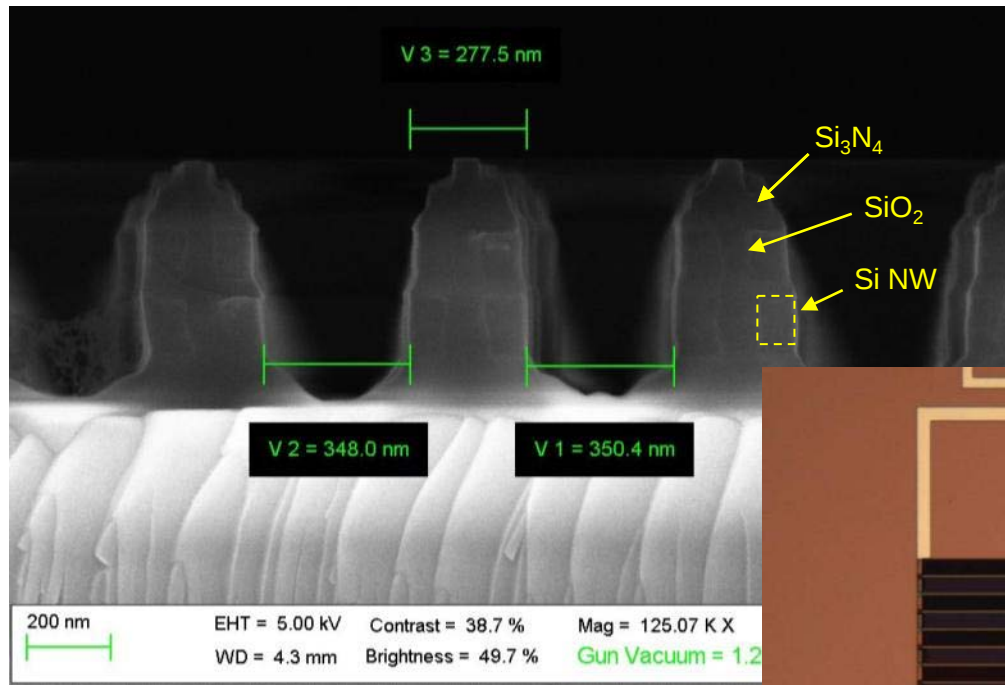
Stacked SiNWs arrays created by **polysilicon** conformal deposition and subsequent etch-back into lateral recessed oxide cavities defined by differential wet etch into multilayered sandwiches of oxide and nitride ... **without nanolithography**





$70 \times 120\ \text{nm}^2$
Arbitrary length (several
hundred microns)

$1.0 \times 10^4\ \text{NWs/mm}$



Thermal Energy Harvesting

**Silicon compatible
BOTTOM-UP nanomaterial
(SiNWs)**

Top-down

Si micromachining:

- 2.5D 'planar' structure
- Areas with thermal contrast

Maximum topographical flexibility at a minimum technological cost



Maximum material flexibility at a minimum technological cost

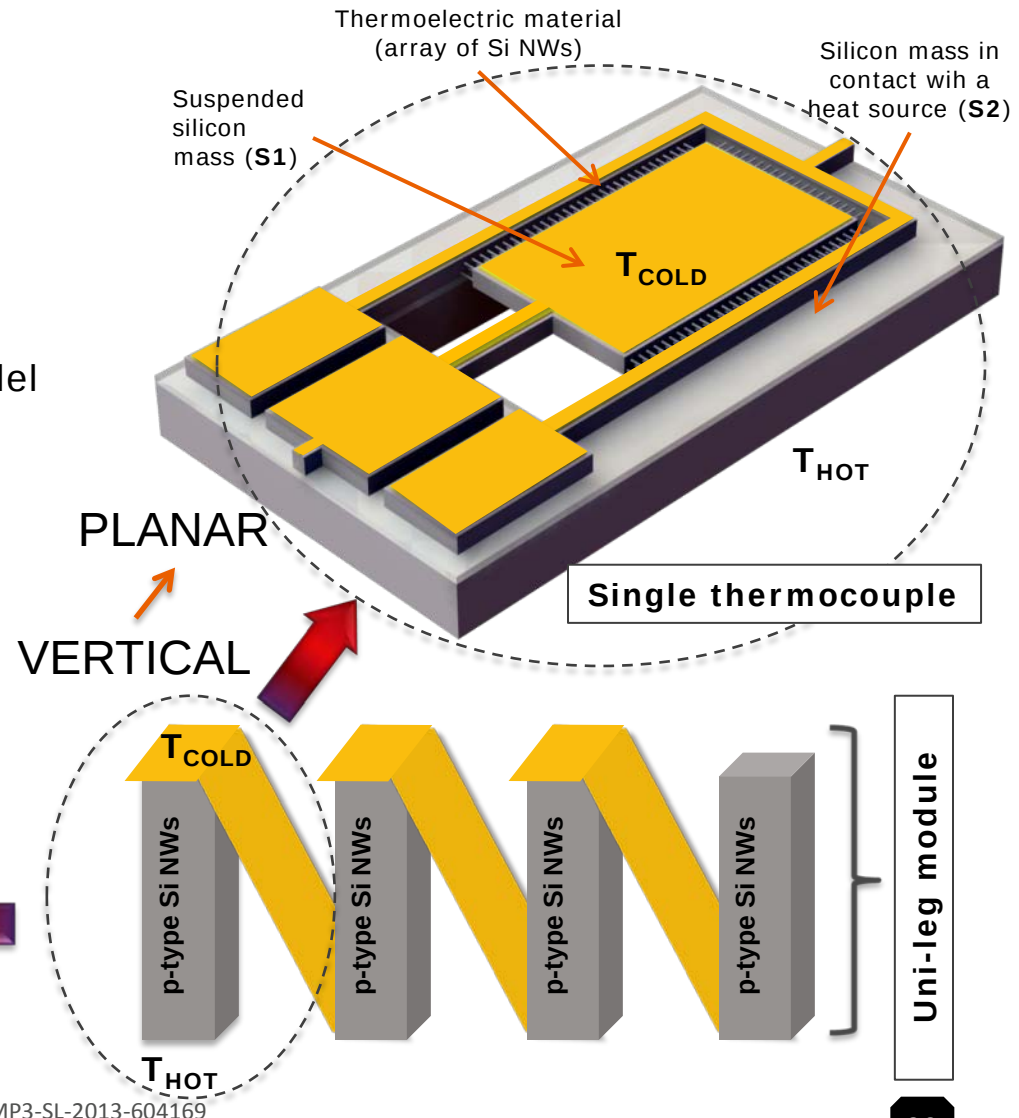
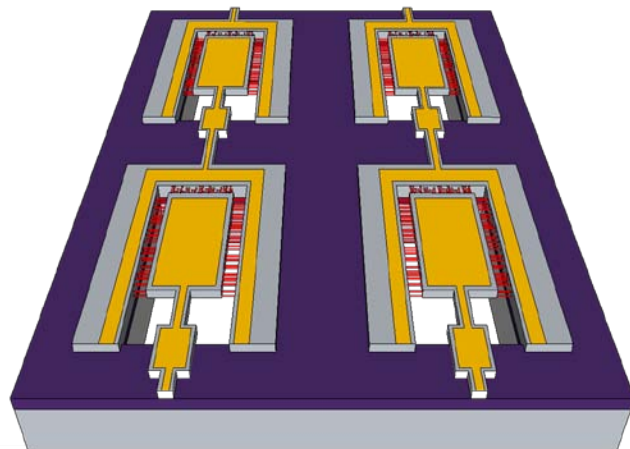
Si NWs growth

- Parallel integration of large numbers of nano-objects

Bottom-up

Unique features:

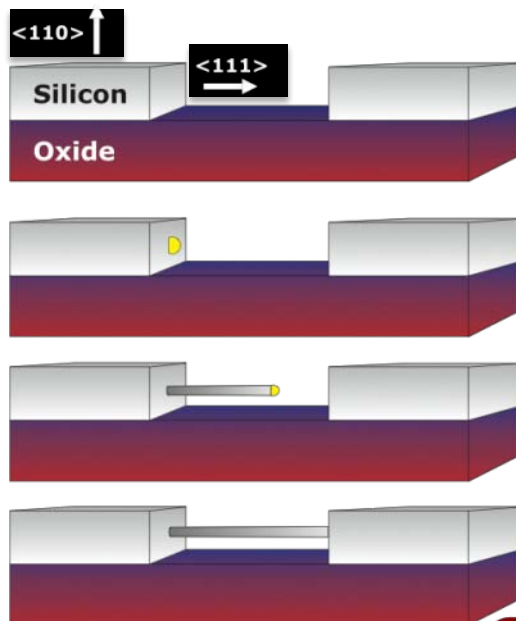
- **Uni-leg** architecture
- Material $\rightarrow$ (all) **silicon**
- “**3D**” SiNWs arrangement (10^6)
- **Planar** architecture
- Scalability $\rightarrow$ series and/or parallel connections



NMP3-SL-2013-604169

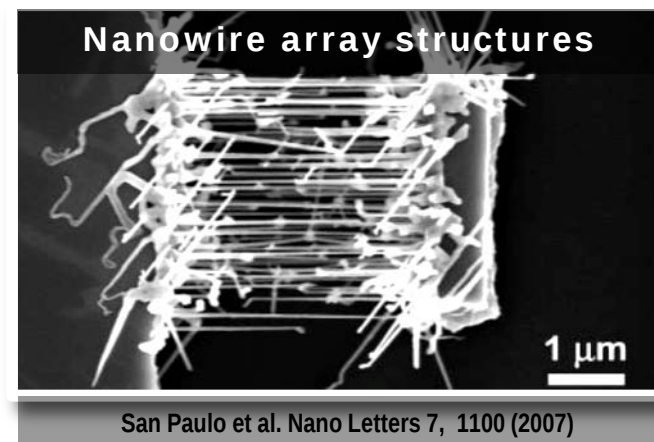
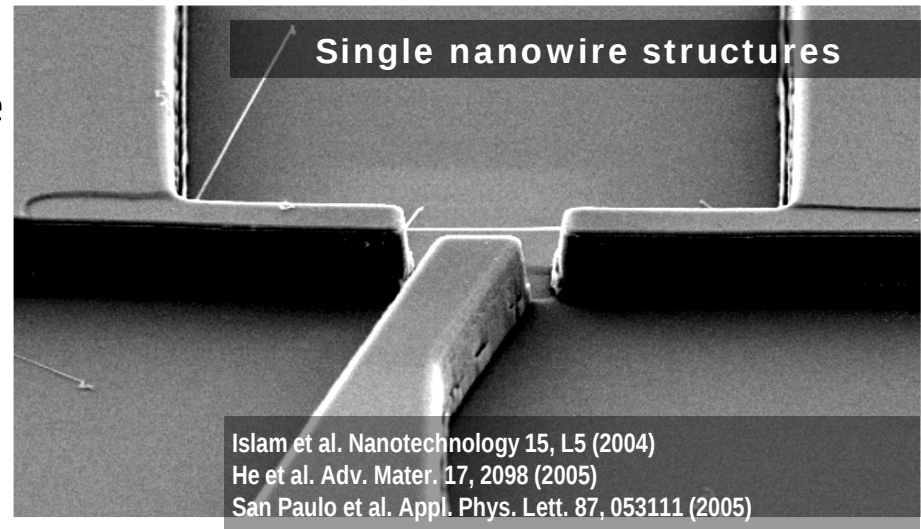
Horizontal growth of Si nanowires

- **Selective** deposition of Au nanoparticle
 - Control of nanoparticle size
 - Deposition only on Si surfaces
- VLS growth method (**quasiepitaxial**)



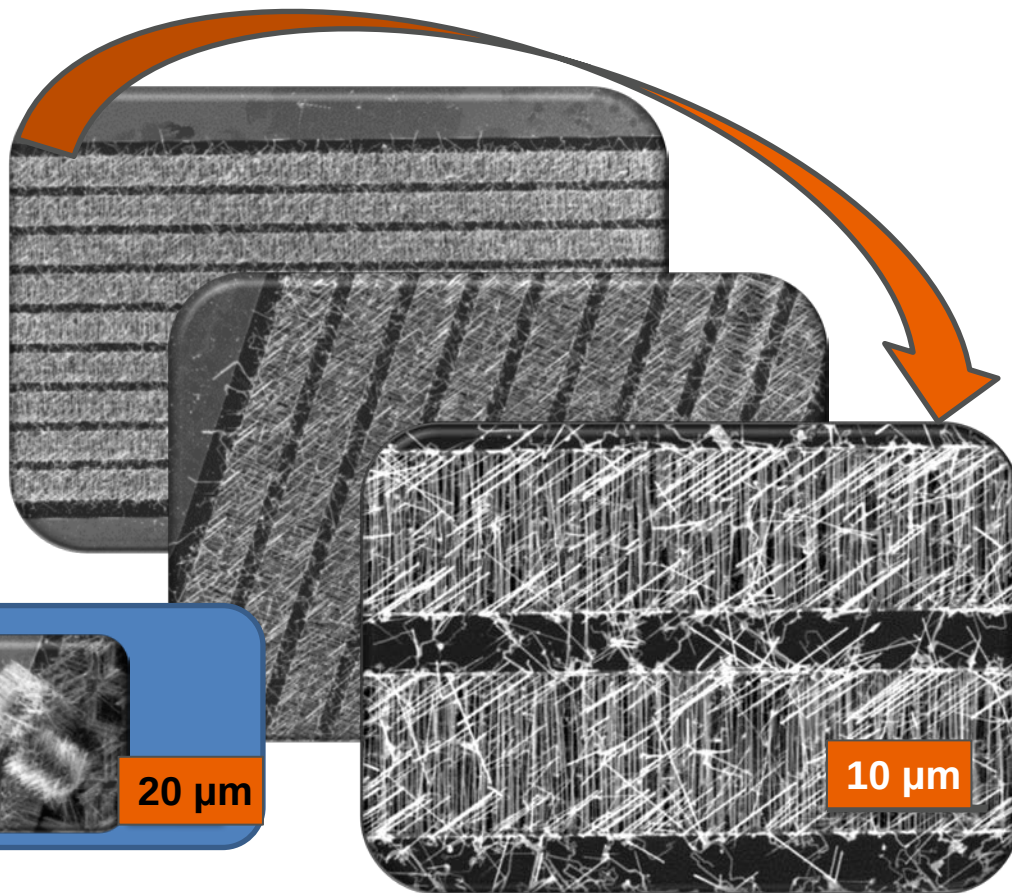
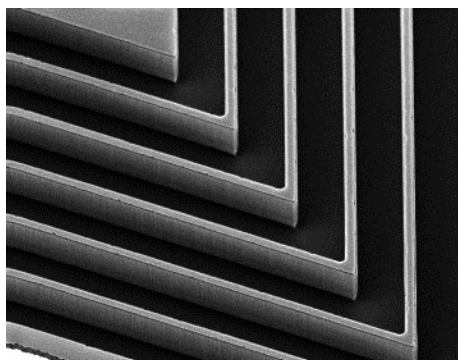
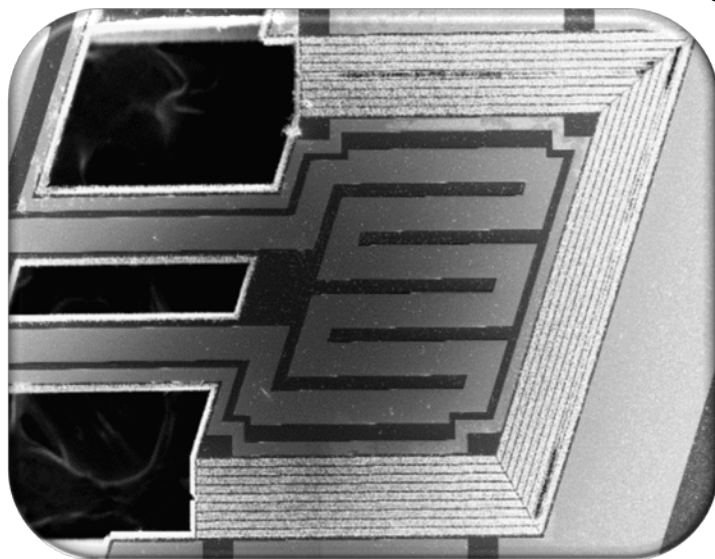
SiH_4
Over 700°C
($\varnothing$ 80-100 nm)

❖ Mechanically robust
❖ Electrically continuous



Multiaarray of Si NWs

- Microspacers: Si lines (3 μ m)
- Multiple linked arrays of Si NWs 10 μ m-long



Mechanical Energy Harvesting

**Silicon compatible
Bottom-up piezoelectric nanomaterial
(ZnO nanoobjects)**

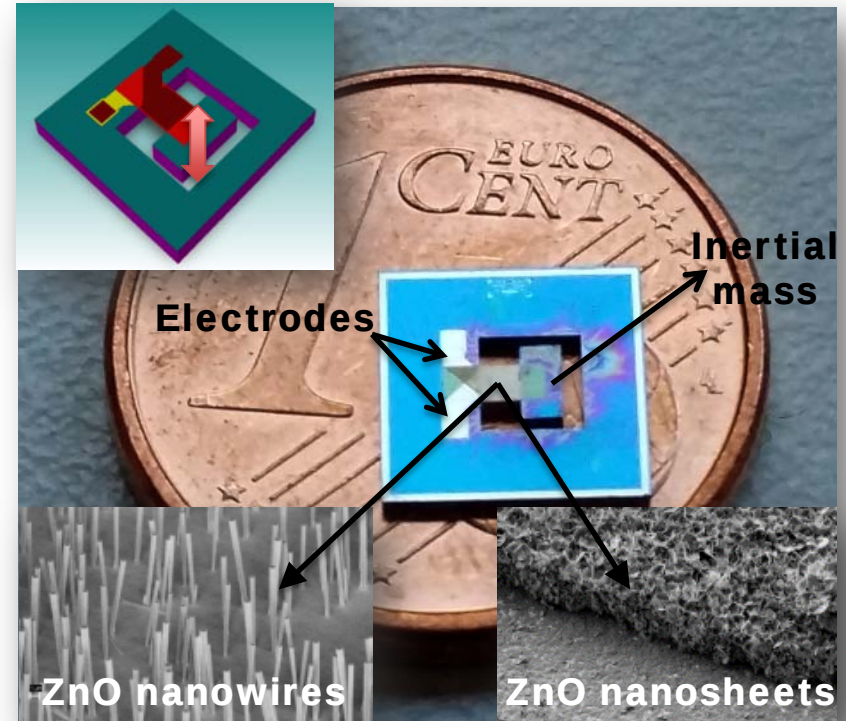
Mechanical energy harvesting: vibrations to electrical energy

- Electrostatic
 - Charged variable capacitor

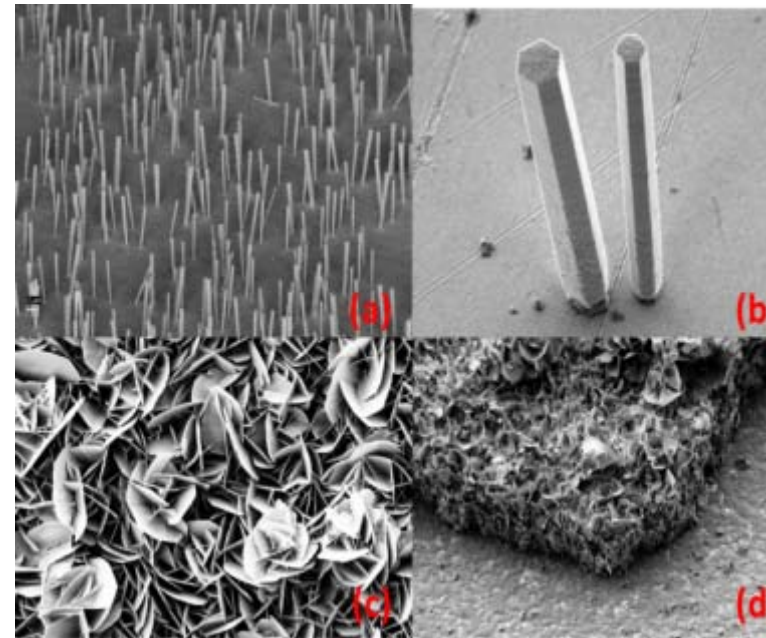
$$P \approx dQ/dt$$

- Piezoelectric
 - Electric charge due to applied stress in piezoelectric material
- ~~• Electromagnetic~~
 - Induction by variable magnetic field

- Piezoelectric energy harvesters – what do we need?
- Inertial mass & cantilevered spring
 - Mass
 - Flexible spring
- Piezoelectric material
 - ZnO nanowires & nanosheets
 - Polymer coating of piezo layer
 - Electrodes



- **Piezoelectric materials - ZnO nanostructures**
- **ZnO nanowires & ZnO nanosheets:**
 - Inherent piezoelectric behavior of ZnO
 - More flexible and robust than thin-films
 - Easy to grow and integrate with silicon, low-cost solution (Hydrothermal synthesis)
 - High novelty provided by ZnO nanosheets

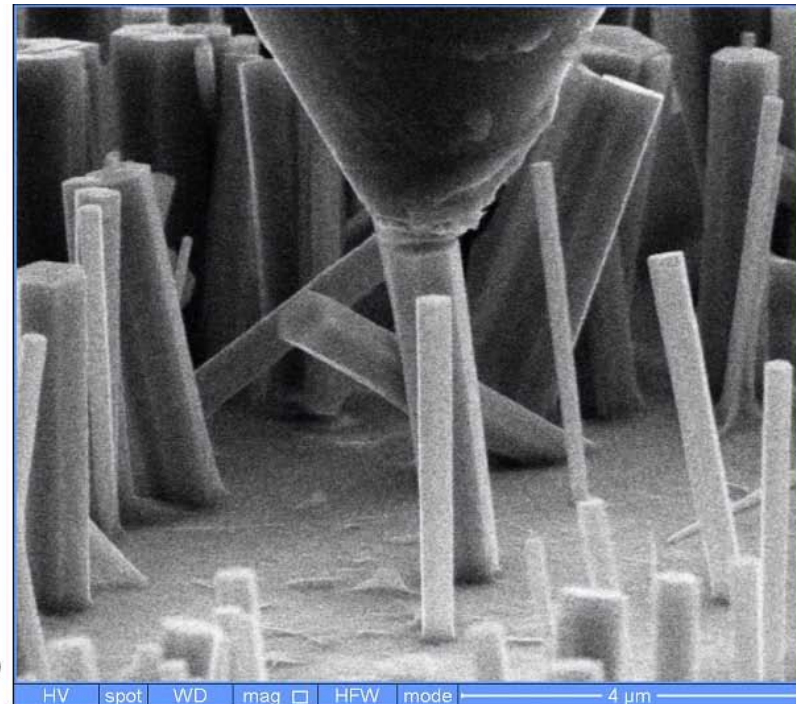
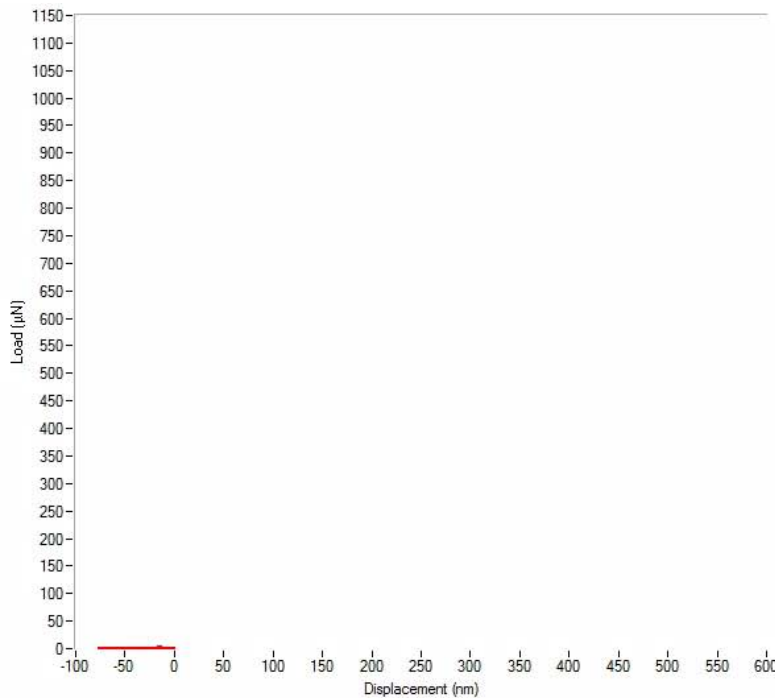


ZnO nanowires (overall view (a) and detailed view (b)), and nanosheets (top view (c) and tilted view (d)). NW lengths range from 2 to 5 μm and thicknesses from 100 nm to 900 nm.

Detailed growth being patented

NMP3-SL-2013-604169

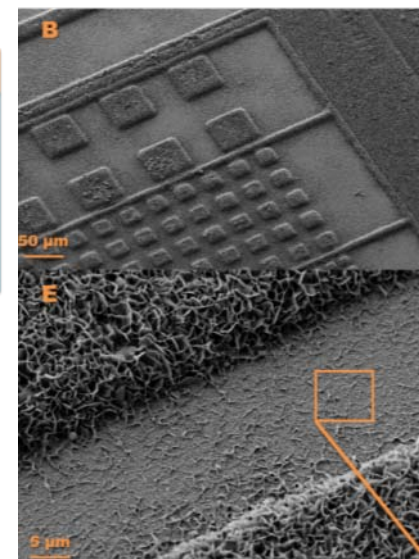
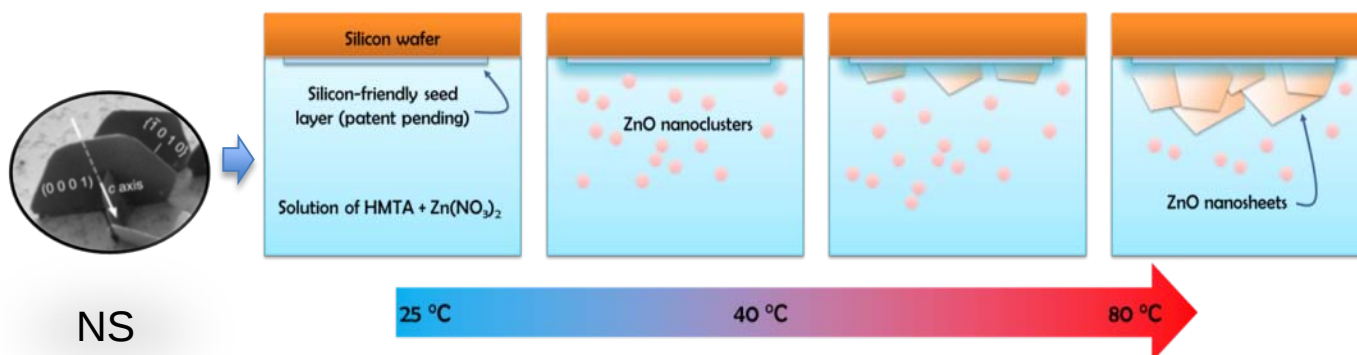
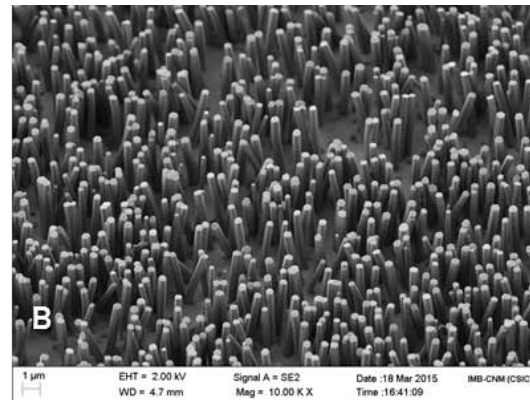
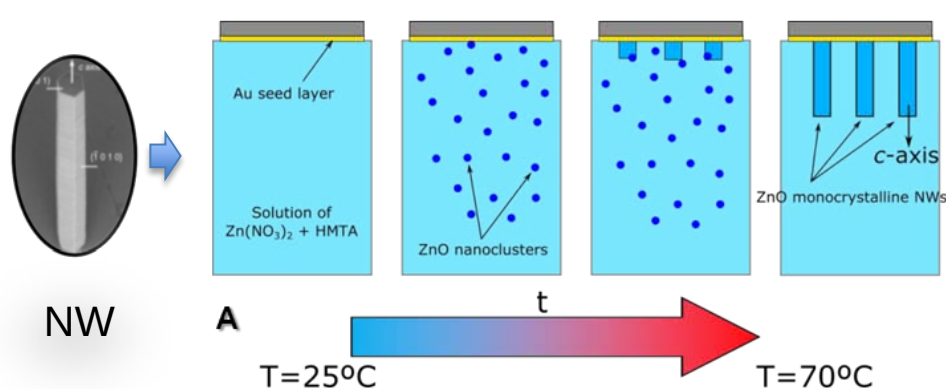
- ZnO nanostructures allow higher compression without fracture.
- It has been demonstrated that a single ZnO NW can stand for a compressing force of more than 1mN!



To be published soon

NMP3-SL-2013-604169

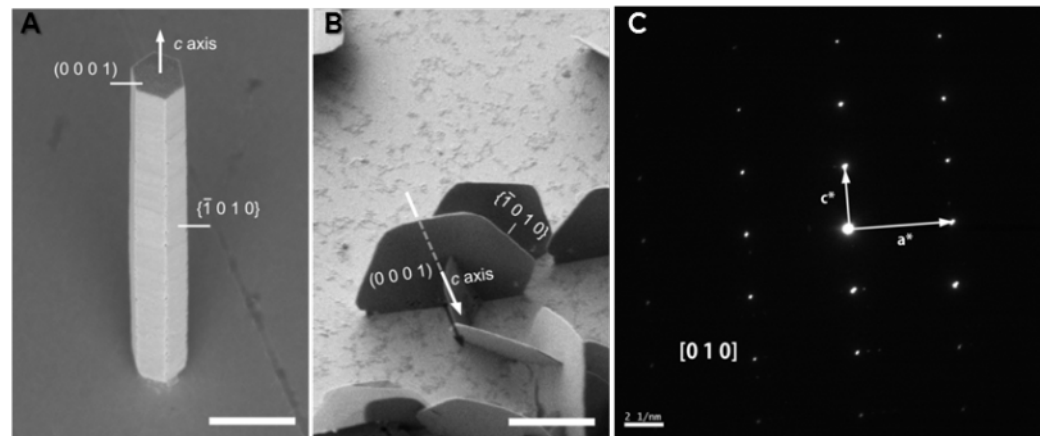
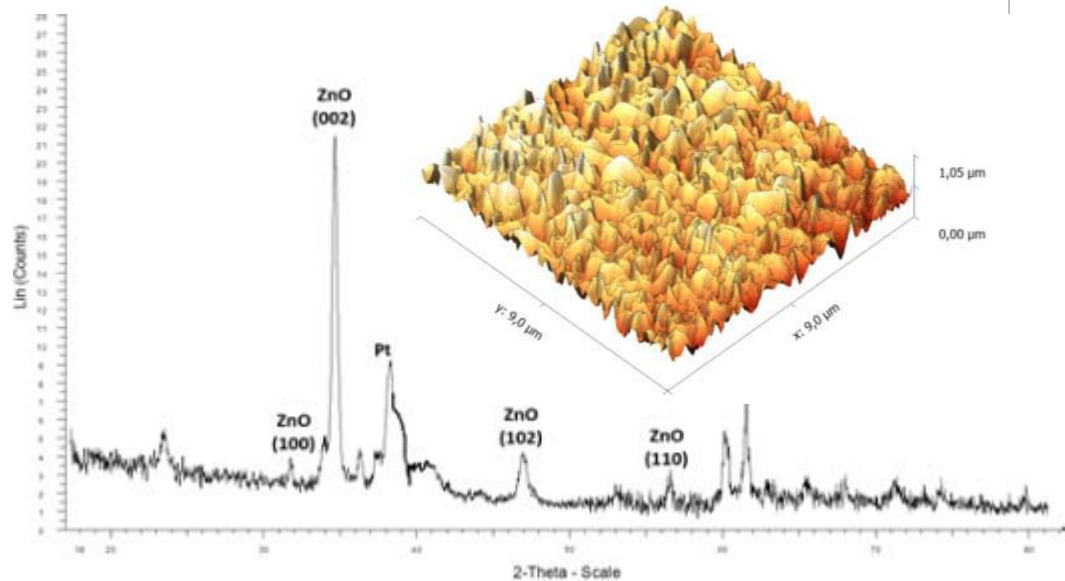
Hydrothermal process (cheap, low T, wafer level and selective)

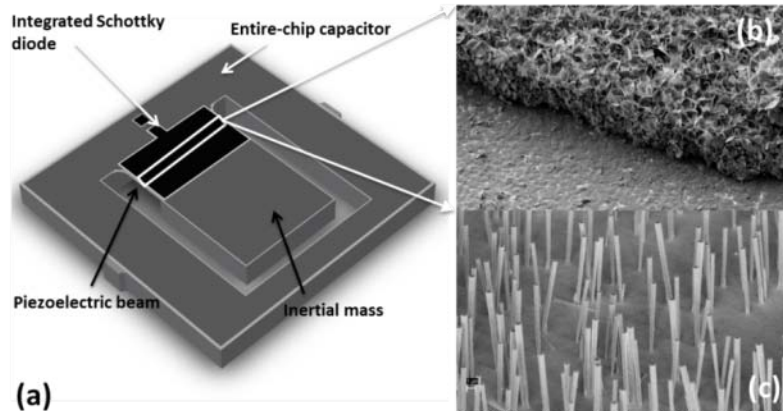


ZnO nanomaterial characterization by TEM, SEM and XRD:

- ZnO NWs & NWs show a **good crystalline structure**.
 - oriented along c-axis (NW) and perpendicular to it (NS)
- **Good piezoelectric coefficient** (measured by PFM: NW: 8.6 pm/V; NS: 4.2 pm/V)
- NS: Thickness < 20 nm, several μm long; **high aspect ratios**
- NS: Extremely high-density, **reproducible and fast**

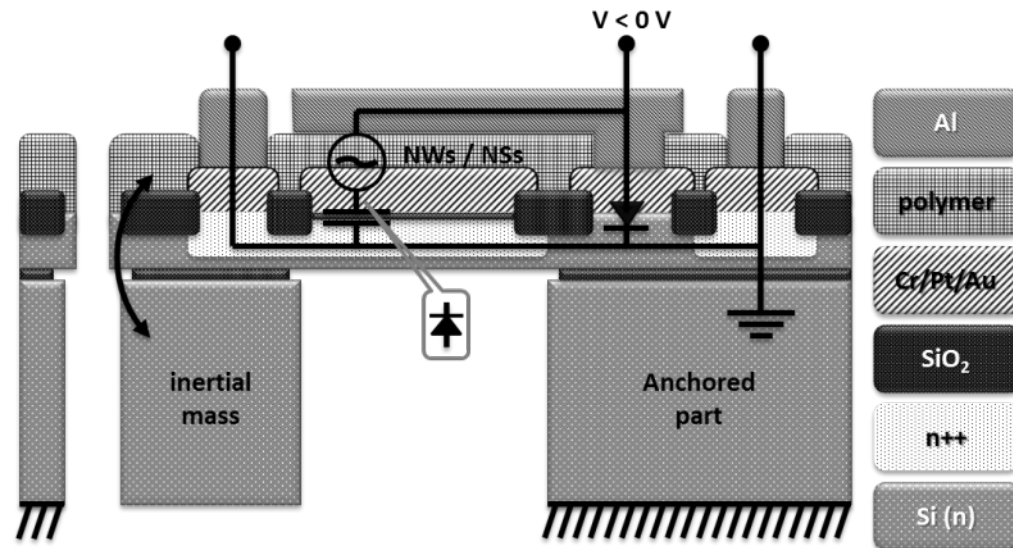
Mechanical harvesting Use of ZnO nanostructures





Integration of ZnO nanomaterial into Si micromachined bending structures

Si device:
On-chip pre-rectification



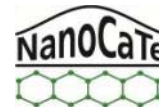
- Without an ‘install and forget’ approach IoT/TS may not happen → (micro)energy autonomy is required
- Energy/power does not (down)scale well → high density features (3D architectures) need to be handled
- Let’s try do harvesters/batteries **with the same technologies that are already used for fabricating miniaturised sensors reliably, cost-effectively and in high numbers** → Si micro-nanotechnologies
- As an example, top-down integration of Si NWs in thermal harvesters has been presented, as well as compatible integration of bottom-up nanomaterials in thermal (Si NWs) and vibrational harvesters (ZnO NW&NS)

This work was supported by FP7-NMP-2013-SMALL-7, SiENERGY (Silicon Friendly Materials and Device Solutions for Microenergy Applications), Contract n. 604169



sinergy-project.eu
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- 2016 E-MRS Spring meeting
 - Symposium W: **Materials and systems for micro-energy harvesting and storage**
 - Materials and system issues for thermal energy microharvesters
 - Materials and system issues for mechanical energy microharvesters
 - Materials and systems issues for microbatteries
 - Materials and system issues for micro supercapacitors





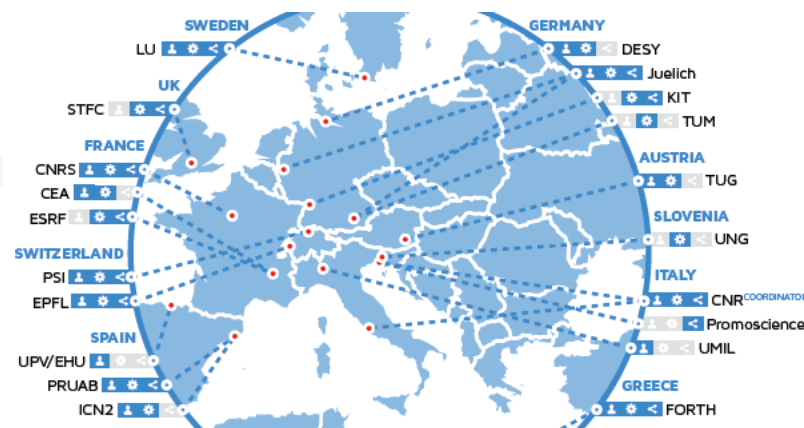
20 European Partners realize a platform supporting comprehensive projects for multidisciplinary research at the nanoscale extending from synthesis to nanocharacterization to theory and numerical

simulation. Specialized synthesis, growth and nanofabrication infrastructures co-located with facilities for the fine analysis and simulation are integrated to develop frontier research on methods for reproducible nanoscience research and to enable European and international researchers from diverse disciplines to carry out advanced proposals impacting science and innovation. NFFA-EUROPE offers access to growth, advanced nano-lithography, nano-

an open access resource for experimental & theoretical nanoscience

simulation. Specialized synthesis, growth and nanofabrication infrastructures co-located with facilities for the fine analysis and simulation are integrated to develop frontier research on methods for reproducible nanoscience research and to enable European

characterization and fine-analysis with Synchrotron, FEL and Neutron radiation sources in a multi-site combination of the state of the art experimental methods.



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